SPCC Clean Panel Discussion

Cuong Tran - Director, Post-CMP Cleans

April 20, 2016



Topics of Discussion

Where do the challenges lay in the formulated clean world?

Is collaboration the key to success?



Challenges for Formulated Clean

#1 Technical

- Fragmentation
 - Each customer is different, each node is different
- Increasing complexity:
 - More materials, increased selectivity, lower defects
- Lack of relevant test vehicles and metrology
 - Only customer wafers tell the story
- Supply chain, quality and change control requirements tightening

#2 Commercial

- Dilutions are increasing
- ASP Pressure intensifies
- Volume per solution significantly reduced

#3 Competition

- Commodity chemicals
- Traditional competitors
- Customers
 - Increased activity in developing formulations and tolling
- OEMs
 - Driving down chemical consumption to improve CoO for tool sales
- Fast followers
 - Increasing numbers of local companies attacking N-2 business (28nm)

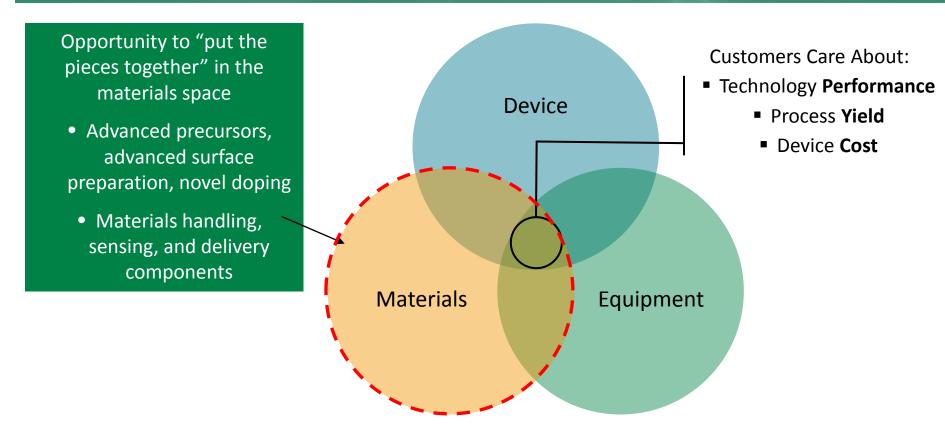


Real World Example for PCMP Cleans

	Formulation A	Formulation B
First Sold	2000	2015
Customers	5	1
Fabs	13	2
Tech Nodes	130 – 28nm	10nm
CoA Parameters	~10	>45
Complexity	-	5x
ASP Expectation	-	-20%
Dilution	<u>-</u>	2x
Volumes	00000000	



Success Depends on Increased Collaboration



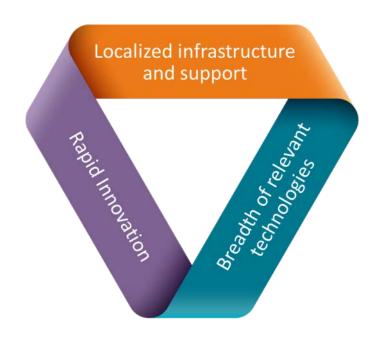
Significant overlap within the Semiconductor Ecosystem

Targeted collaborations are the key to profitable solutions for all parties



Accelerating Development Cycles and Improving Yields

- Combine capabilities to unlock new value
 - Technical capability for rapid innovation
 - Breadth of technologies
 - Global reach, local support
- Enable new paradigms within the semiconductor ecosystem
 - Wet chemistries and wetted surfaces
 - Gases and gas-wetted surfaces
 - Solids and solid material delivery
- Create differentiated solutions to accelerate customer yield ramps



Enable the customers to focus on process integration and product performance



